

**In the Specification:**

*Please amend the specification as follows:*

On page 1, immediately following the title, please add the following heading:

Cross-References to Related Applications

On page 1, line 2 (*i.e.*, immediately before the paragraph that begins with "This invention relates to..."), please add the following heading:

Field of the Invention

On page 1, line 5 (*i.e.*, immediately before the paragraph that begins with "One specific class of opto-electrical devices..."), please add the following heading:

Description of Related Art

On page 2, line 14 (*i.e.*, immediately before the paragraph that begins with "According to one aspect..."), please add the following heading:

Summary of the Invention

On page 7, line 4 (*i.e.*, immediately before the paragraph that begins with "The present invention will now be described..."), please add the following heading:

Brief Description of the Drawings

On page 7, line 17 (*i.e.*, immediately before the paragraph that begins with "The device of figure 2 comprises..."), please add the following heading:

Detailed Description of the Invention

Please amend the paragraph beginning on page 8, line 11, as follows:

Then the electroluminescent layer ~~45~~ 12 is deposited. In this example, the electroluminescent layer is formed of 20% TFB in 5BTF8. The term 5BTF8 refers to poly(2,7-(9,9-di-*n*-octylfluorene) ("F8") doped with 5% poly-(2,7-(9,9-di-*n*-octylfluorene)-3,6-benzothiadiazole) ("F8BT"). The ~~the~~ term TFB refers to poly(2,7-(9,9-di-*n*-octylfluorene)-1,4-phenylene-((4-secbutylphenyl)imino)-1,4-phenylene)). This mixture is coated over the hole transport layer by spin-coating typically to a thickness of around 750 Å. Other materials such as PPV could be used for the emissive layer. The emissive layer could be formed by other routes such as blade or meniscus coating and could be deposited in precursor form if desired.